

Attorney Docket No. 262/014

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re patent application of

Byung-Hee KIM, et al.

Serial No. 10/035,257

Filed: January 4, 2002

Group Art Unit: 2822

Examiner: M. Guerrero

For: METHOD OF FABRICATING METAL LINES IN A SEMICONDUCTOR DEVICE

Fee only

**INFORMATION DISCLOSURE STATEMENT
UNDER 37 C.F.R. §1.56**Commissioner for Patents
Alexandria, VA 22313-1450

Sir:

Submitted herewith on Form PTO/SB/08 (or PTO-1449, *modified*) is a listing of a document(s) known to applicant in order to comply with applicant's duty of disclosure pursuant to 37 C.F.R. §1.56.

☒ A copy of each listed document is being submitted to comply with the provisions of 37 C.F.R. §§1.97 & 1.98. [Box checked if applicable.]

☐ A copy of each listed non-U.S. patent and/or patent publication and cited literature is being submitted to comply with the provisions of 37 C.F.R. §§1.97 & 1.98. Cited U.S. patents and patent publications are *not* attached in accordance with the waiver set forth in the Notice by the Deputy Commissioner for Patent Examination Policy dated July 11, 2003, applicable to applications having a U.S. filing date *after* June 30, 2003. [Box checked if applicable.]

The submission of any document herewith, which is not a statutory bar, is not intended as an admission that such document constitutes prior art against the claims of the present application. Applicant does not waive any rights to take any action that would be appropriate to antedate or otherwise remove as a competent reference any document which is determined to be a *prima facie* prior art reference against the claims of the present application.

04/30/2004 TBELL1 00000002 501645 10035257